



10/727,451

PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of:

Peter J. Hopper, et al.

Appln. No.: 10/727,451

Filed: December 3, 2003

For: METHOD OF FORMING A DUAL
DAMASCENE METAL TRACE WITH
REDUCED RF IMPEDANCE RESULTING
FROM THE SKIN EFFECT (as
amended)

Group Art Unit: 2812

Examiner: Ha T. Nguyen

AMENDMENT IN RESPONSE TO OFFICE
ACTION DATED JANUARY 23, 2006

INTRODUCTORY COMMENTS

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Dear Sir:

In response to the Official Action mailed January 23, 2006, please amend the
above-identified application as follows:

Amendments to the Claims are reflected in the listing of claims which
begins on page 2 of this paper; and

Remarks which begin on page 8 of this paper.

AMENDMENT IN RESPONSE TO OFFICE
ACTION DATED JANUARY 23, 2006

Atty. Docket No. 100-18012
(P05268-D01-F2)